

# WEST Search History

DATE: Thursday, October 23, 2003

<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
			result set
<i>DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
L7	L6 and (ultrasonic\$5 or megasonic\$5 or transducer)	7	L7
L6	L4 and (((semiconductor or wafer or substrate) with (clean\$3 or wash\$3 or rins\$3 or immers\$3)) same (water or 'H.sub.2O') same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2'))	7	L6
L5	L4 and l2	0	L5
L4	yeol\$.in.	495	L4
L3	L2 and l1	15	L3
L2	((semiconductor or wafer or substrate) with (clean\$3 or wash\$3 or rins\$3 or immers\$3)) same (water or 'H.sub.2O') same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2') same (ultrasonic\$5 or megasonic\$5 or transducer)	46	L2
L1	((134/1.3  134/3  134/18  134/26  134/28  134/30  134/902 )!.CCLS.  (438/906 )!.CCLS. )	7103	L1

END OF SEARCH HISTORY